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Philips Semiconductors



Polley

June 9, 1999

James P. Bearzi
Hazardous and Radioactive Materials Bureau
New Mexico Environment Department
2044A Galisteo St.
Santa Fe, NM 87505

Certified Mail: P 330 324 495

**SUBJECT: Request to Change Groundwater Sampling
Hazardous Waste Permit #NMD000709782-1**

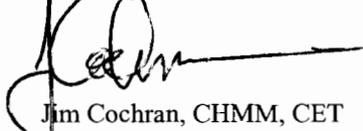
Dear Mr. Bearzi:

We are requesting that our permit requirement for groundwater monitoring be changed from sampling for all of the RCRA Appendix IX constituents on a quarterly basis to sampling for the volatile compound list on an annual basis.

Philips has monitored wells , MW-1, MW-2, MW-3, and MW-4 for over eight quarters (in addition to eight years of voluntary monitoring). Philips has also voluntarily monitored five new wells installed by the City of Albuquerque on this site since their installation. The only organic compound that has been consistently detected is tetrachloroethylene (PCE) and its concentration has not changed over time, see attached figure.

Because the levels of PCE have not changed significantly and it is the only parameter on the Appendix IX list that has been detected above standards, we feel that this expenditure is not value-added. We would appreciate your prompt decision on this matter. If you have any questions, please call our technical contact, Joe Mauser at (505) 822-7634.

Sincerely,


Jim Cochran, CHMM, CET
EHS Manager

(ENV919)

Enclosure

cc: File

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PHILIPS SEMICONDUCTORS - ALBUQUERQUE

Groundwater Analysis

Tetrachloroethene (PCE) Concentration in ppb

